

Structure Data of Free Polyatomic Molecules

293
ED

I₄Si
Silicon tetraiodide
Tetraiodosilane

T_d
SiI₄

r_g	\AA^a	θ_a	deg^a
Si-I	2.432(5)	I-Si-I	109.4(1)

The nozzle temperature was 378 K.

^a) Estimated total error.

 Kolonits, M., Hargittai, M.: Struct. Chem. **9** (1998) 349.
